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AUG 17 2005

**METHOD OF FORMING A PHOTO SENSOR ON SEMICONDUCTOR WAFER  
WITH OVERLAPPED REGION**

Appl. No.	:	10/065,296	Confirmation No. 5720
Applicant	:	Liang-Hua Lin, Anchor Chen	
Filed	:	October 1, 2002	
TC/A.U.	:	2813	
Examiner	:	Erik J Kielin	
Docket No.	:	NAUP0477USA1	
Customer No.	:	27765	

Commissioner for Patents  
P.O. Box 1450  
Alexandria VA 22313-1450

**AMENDMENT**

5 Sir:

In response to the Office action of February 16, 2005, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

10 **Remarks/Argumnts** begin on page 5 of this paper.